

Page 1 of 26

ESCC QUALIFIED MANUFACTURERS LIST

REP006

ISSUE 10

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ISSUE 10

DOCUMENTATION CHANGE NOTICE

(Refer to https://escies.org for ESCC DCR content)

DCR No.	CHANGE DESCRIPTION	
786	Document updated to incorporate changes per DCR.	



ISSUE 10

FOREWORD

This document contains a list of qualified manufacturers that have been certified by the European space agency for technology flows to the rules of the ESCC system with principle reference to ESCC Basic Specification no. 25400.

The qualified electronic components produced from the technology flows are intended for use in ESA and other spacecraft and associated equipment in accordance with the requirements of the ECSS standard ECSS-Q-ST-60.

Each technology flow qualification and its subsequent maintenance is monitored and overseen by the ESCC executive. ESA certifies the qualification upon receipt of a formal application from the executive stating that all applicable ESCC requirements have been met by the pertinent manufacturer. The qualified status of a technology flow is noted by an entry in this document, a corresponding entry in the European space components information exchange system, ESCIES, and the issue of a certificate to the qualified manufacturer.



ISSUE 10

PAGE 5

TABLE OF CONTENTS

1	PROMOTION	6
2	PROCURER'S RESPONSIBILITY	6
3	QML ORGANISATION	6
3.1	TECHNOLOGY FLOWS	6
3.2	QUALIFIED COMPONENTS	6
3.3	TYPE DESIGNATION	6
3.4	COMPONENT CHARACTERISTICS	6
3.5	MANUFACTURER	6
4	REVISION PROCEDURE	7
5	QUALIFIED TECHNOLOGY FLOWS	7
5.1	ATMEL	7
5.2	VISHAY S.A. FRANCE	12
5.3	NORSPACE, NORWAY	16
5.4	ATMEL	21



1 PROMOTION

It is permitted to advertise the ESCC qualification status of a component provided such publicity or advertisement does not state or imply that the component is the only qualified one of that particular type, range or family.

2 PROCURER'S RESPONSIBILITY

When procuring ESCC qualified components, the procurer is responsible for ensuring that the qualification status is valid and that delivered components fulfil the specified requirements of the applicable ESCC specifications. The procurer is advised to utilise the ESCC non- conformance system, per ESCC Basic Specification No. 22800, in the event that a qualified manufacturer delivers non-conforming components.

3 <u>QML ORGANISATION</u>

3.1 <u>TECHNOLOGY FLOWS</u>

The individual Technology Flows are listed in this document by manufacturer in alphabetical order. They may also be found on the ESCIES web site, https://escies.org.

The controlling ESCC specifications are identified and a Technology Flow Abstract is provided to describe the main features of the qualified Technology Flow.

3.2 QUALIFIED COMPONENTS

Under each technology flow a list of the qualified components is provided. As new components are specified in an ESCC Detail Specification and are produced within the Technology Flow the list will be updated accordingly.

3.3 <u>TYPE DESIGNATION</u>

Wherever possible the referenced type (style) designations are derived from industrial standards (i.e., JEDEC, PRO-ELECTRON, MIL, IEC and CECC). The purpose is to identify the similarity of a listed qualified component, to a standard type designation. Where no standardised type designation is applicable the manufacturer's designation is referenced.

3.4 COMPONENT CHARACTERISTICS

The electrical characteristics described in the Technology Flow Abstract are provided for guidance only and, unless otherwise stated, are specified at +25°C. The precise characteristics of the qualified component are defined in the referenced ESCC specifications.

3.5 <u>MANUFACTURER</u>

Contact information and plant locations are indicated in the individual Technology Flow listings. Contact information may also be found in the ESCC QML section of the ESCIES web site, https://escies.org.



4 REVISION PROCEDURE

Amendments to earlier issues of the ESCC QML, implemented herein, are indicated by the issue date and by the content of the relevant "Document Change Request".

5 QUALIFIED TECHNOLOGY FLOWS

The following Technology Flows are qualified:

5.1 <u>ATMEL</u>

Contact Information

Address	ESCC Chief Inspector
BP 70602	Mr C. Ferré Tel. +33 24 01 81 913 FAX +33 24 01 81 946

Initial Qualification

Qualification Certificate No.	Validity Dates	Type Designation
278		Integrated Circuits, Silicon Monolithic, CMOS Gate/ Embedded Array based on type MH1RT

Maintenance of Qualification

Qualification Certificate No.	Validity Dates	Comment
278A	April 2010 - December 2010	Changes to the Technology Flow Abstract were introduced.
278B	December 2010 - December 2011	CNES application 278B and DCR 647

ESCC Generic Specification No. 9000

ESCC Detail Specification No. 9202/076

Atmel Process Identification Document PID 0026

List of Qualified Components



For each ASIC design an ASIC Sheet is produced by Atmel for use in conjunction with the ESCC Detail Specification No. 9202/076. Where the ASIC is not proprietary to the customer the ASIC sheet is published in ESCIES as a supporting document. Availability of the ASIC sheet is indicated in the table by an * in the final column.

ASIC Sheet	Component Type	ESCIES
FPK	Integrated Motor Controller for Mechanisms	*

Technology Flow Abstract

1. Technology Flow

The MH1RT gate array family is designed with a 0.35µm radiation tolerant CMOS technology. The offering is based on a 4 metal layer 3.3volts AT56KRT process.

The family features arrays with up to 1.6 million routeable gates and 596 pads. The MH1RT is suitable for high speed, low power digital applications working in a radiation intensive environment.

The Technology Flow covers the foundry design, fabrication, assembly and testing of the

MH1RT Sea of Gates family.

	Scope	Site
Design Centre	Array Sizes: - 99K - 156K - 242K - 332K - 3V and 5V tolerant/compliant	Atmel Nantes BP 70602 44306 Nantes Cedex 3 France
Wafer Fabrication	Process Flow: AT56KLRT	LFoundry Rousset Zone Industrielle 131106 Rousset Cedex France



	Scope	Site
Assembly	Packages: - Multilayer Quad Flat Pack 196, 256, 352 pins	E2V Grenoble BP 123 38521 Saint-Egrève Cedex France
Test	Lot Formation Wafer Acceptance Inspection - SEM - Wafer Lot Acceptance In-process Inspection Test Testing Flow Sampling Plans Test Procedures - Test Vector Generation - Test Program Validation Customer Source Inspection Qualification Testing Lot Acceptance Support Qualification Test Plan/Report Technology Characterization Reliability Monitoring	Atmel Nantes BP 70602 44306 Nantes Cedex 3 France
	Incoming Inspection Final Test - Credence, Type Octet Screening External Visual Inspection	Atmel Nantes BP 70602 44306 Nantes Cedex 3 France

(b) Basic Information

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- 0.35 µm CMOS technology AT56KRT Process.
- High Speed Performance
 - 170 ps typical gate delay (NAND, fanout 2) @ 3V
 - 800 MHz typical toggle frequency @ 3.3V
- Triple Supply Operation
 - 3.3, 3 and 2.55 V operation
 - 5V compliant
- Low Supply Current
 - Operating Maximum Value
 - 0.32 W/gate/MHz @ 2.5V,
 - 0.54 W/gate/MHz @ 3V,
 - 0.69 W/gate/MHz @ 3.3V
 - Maximum Stand-by Value
 4nA/gate@ 2.5V
 En A/gate@ 2.and 2.2V
 - 5nA/gate@ 3 and 3.3V
- 472 pins maximum (MCGA 472 package)
- I/O Interface
 - CMOS, LVTTL, LVDDS, PCI, USB
 - Output Currents Programmable from 2 to 24 mA, by Steps of 2 mA
 - Cold Sparing Buffers (2 µA maximum leakage current at 3.6V and 125oC)
- Radiation



- **ISSUE 10**
- qualified to 1000 Gy(Si) letter R per ESCC Basic Specification No. 22900, tested successfully to 2000 Gy(Si)
- No Single Event Latch-up below a LET Threshold of 70 MeV/mg/cm²
- SEU Hardened Flip-flops
- Four Arrays and Four Composite Arrays
 - Device Types
 - Refer to ESCC Detail Specification No. 9202/076

(c) Component Types

This table presents the available couples (array, package) as defined in the Variants table in the Detail Specification.

	TH1099E	TH1156E	TH1242E	TH1332E
Array Designation	TH1M099E	TH1M156E	TH1M242E	TH1M332E
Array size	99K	156K	242K	332K
Package				
MQFP-T352	Х	Х	Х	Х
MQFP-F256	Х	х	Х	
MQFP-F196	Х			

2. Design

The design manual and the ASIC library data books cover design at the Atmel Nantes Design Centre.

- MH1RT Design Manual ATD-TS-LR-R0232
- MH1RT 2V5 ASIC Library Data book ATD-TS-LR-R0236
- MH1RT 3V ASIC Library Data book ATD-TS-LR-R0235
- MH1RT 3V3 ASIC Library Data book ATD-TS-LR-R0238

ASIC designs are performed by the Atmel customer at their own site, with Atmel supported tools (front end) provided as a design tool kit.

3. Fabrication

The AT56KRT Radiation Tolerant process at Atmel Rousset is a 0.35 μ m CMOS, 4 metal, Ti, TiN and AlCu process.

4. Assembly

Atmel Nantes assembles the MH1RT devices at E2V Grenoble. This Technology Flow covers the following capabilities. Solderability testing for MCGA packages is included.

Die attach for MQFP package is Cyanate Ester (JM7600).

Package	Die Attach	Wire Bond	Lid Seal	Leads
MQFP	Cyanate Ester (JM7600)	Ultrasonic Wedge, 32 µm Al	Brazed Sealed with Au/Sn Alloy	Au Plated





5. Test TCVs and SEC

The TH1156E matrix is used for both test vehicles.

- (a) Test Vehicle V37 The V37 is a buffer test vehicle representative of the range of buffers available for performance testing in the MQFP 256 package.
- (b) Test Vehicle V38

The V38 is developed for performance and radiation testing in the MQFP 256 package. It tests the following library elements;

- LVDS input and output buffers
- PCI 3V and 5V output buffers
- PLL (125 MHz and 250 MHz)
- DPRAM memory cell for GENESYS tool
- (c) SEC The standard evaluation circuit for reliability testing is the 65609E.
- (d) The use of Transition Delay Fault (TDF) vectors are recommended.
- 6. Radiation Characteristics

The MH1RT family has been developed to fulfil the following characteristics in terms of radiation tolerance:

- Tested up to 2000 Gy(Si)
- No Single Event Latch-up below a LET Threshold of 70MeV/mg/cm²
- Availability in the library of SEU hardened cells

The radiation capability of the MH1RT family has been tested during development and evaluated in total dose and for single event effects to confirm the stated characteristics. Lot radiation verification testing is performed if specified by the procurer's purchase order requirements.



5.2 <u>VISHAY S.A. FRANCE</u> Contact Information

Address	ESCC Chief Inspector
Vishay S.A. Division SFERNICE 199, Boulevard de la Madeleine CS71159 F-06003 Nice Cedex 01 France	Mr. L. Cresson Tel: +33 4 93 37 27 88 FAX: +33 4 93 37 28 77 EMAIL: <u>laurent.cresson@vishay.com</u>

Initial Qualification

Qualification Certificate No.	Validity Dates	Type Designation
287	Feb. 2009 - Feb. 2011	Thin Film Technology for Chip, Wraparound, Single and Network Resistors, Fixed, Based on Types P for Single Chip, PRA and CNW for Resistor Networks

Maintenance of Qualification

Qualification Certificate No.	Validity Dates	Comment
287A	Feb. 2009- Feb. 2011	CNES application no. 287A and DCR 528.
287B	Feb. 2011 to Feb. 2013	CNES application no. 287B and DCR 650.

Applicable Documents

ESCC Generic Specification No. 4001

ESCC Detail Specification Nos. 4001/023, 4001/025

Vishay S.A. Process Identification Document PID PID-TFD P PRA CNW

List of Qualified Components



Variant No. By Form Factor (2)	Component Type	ESCC Detail Specification
15	PFRR- P 0402 FR Failure Rate Level R	4001/023
09	PFRR- P 0603 FR Failure Rate Level R	4001/023
01 and 05	PHR- P 0603 HR	4001/023 (1)
10	PFRR- P 0805 FR Failure Rate Level R	4001/023
02 and 06	PHR- P 0805 HR	4001/023 (1)
11	PFRR- P 1206 FR Failure Rate Level R	4001/023
03 and 07	PHR- P 1206 HR	4001/023 (1)
12	PFRR- P 2010 FR Failure Rate Level R	4001/023
04 and 08	PHR- P 2010 HR	4001/023 (1)
01 to 07 and 22 to 28	PRA 100 HR	4001/025
08 to 14 and 29 to 35	PRA 135 HR	4001/025
15 to 21 and 36 to 42	PRA 182 HR	4001/025

NOTES:

- 1. Note that gold finish variants are not intended for de-golding and tinning.
- 2. The electrical ranges of these ESCC QML Qualified components variants are listed in the ESCC Detail Specifications and in the Qualified Part List (REP005) document available on the ESCIES website, https:// escies.org.

Technology Flow Abstract

- 1. Technology Flow
 - The thin film technology for chip, fixed, wraparound, single and network resistors are designed on types based on P for single chip, PRA for 2 to 8 resistors of similar value and CNW for 2 to 8 resistors with at least two different values with the same form factor as PRA.

Technology Flow	Scope	Site
Design Centre	Single resistor chips in 0402 0603, 0805, 1206 and 2010 formats 2 to 8 resistors of similar value in formats 0603, 0805 and 1206 2 to 8 resistors with at least 2 different values with the same form factor, 0603, 0805 or 1206	Vishay S.A. Division SFERNICE 199, Boulevard de la Madeleine CS71159 F-06003 Nice Cedex 01 France



Fabrication	Film deposition Photolithography Thermal treatment Passivation Thermal stabilization and control	As above
Assembly	Laser trim Protective layer Termination and Test	As above
Test	Chart F2, F3 and F4 Periodic Testing	As above

(a) Basic Information

The technology consists of:

- Substrate: High purity alumina (99.5%)
- Resistive Layer: Nickel chromium
- Passivation Layer: Silicon Nitride
- Protection: Epoxy and Silicone
- Termination: Nickel barrier
- Processes: Thin film deposition
- Finish: SnPbAg or Au

Critical resistance by style:

- P 0402 FR:32 k
- P 0603 FR:25 k
- P 0603 HR:12.25 k
- P 0805 FR: 80k
- P 0805 HR: 45 k
- P 1206 FR: 90 k
- P 1206 HR: 40 k
- P 2010 FR: 80k
- P 2010 HR: 45 k
- PRA 100: 12.25 k
- PRA 135: 56.25 k
- PRA 182: 100 k

(b) Component Types

The available formats are defined in the variants table in the Detail Specifications. Variants with established reliability in accordance with Basic specification No. 26000 are designated with an "FR" suffix here for convenience. Variants 09, 10, 11 and 12 have established reliability level 'R' at 60% confidence level.

2. Design

The design manuals covers the design rules and limits:

- HP-BE/001 (Maîtrise de la conception)
- HP-BE/004 (Données technologiques, Régles d'implementation, Performances)

Critical design characteristics:





- Minimum metal width: 10 μm
- Power dissipation lower than 250mW/mm²
- Current density lower than 7000 A/mm²
- Electrical field lower than 5V/ μm
- Fabrication/Assembly The manufacturing flows and procedures are described in section 4 of Vishay S.A.PID.
- Test Complete test sequence as detailed in ESCC Generic 4001 and the relevant Detail Specifications is conducted by Vishay S.A.

The deletion of the Third Harmonic Control requirement from ESCC Detail Specification No. 4001/023 for thin film wraparound technology is documented in reference report MAT/ 3HC/07.02 revision 3 dated 2007-06-20.

For variants with established reliability the efficiency of the Overload Test is increased with the implementation of a resistance change rejection criteria of 500 ppm and approved by TRB decisions on 2007-04-04.

 Radiation Characteristics The resistors covered in this technology domain is considered insensitive to radiation effects.



5.3 <u>NORSPACE, NORWAY</u> Contact Information

Address	ESCC Chief Inspector
Norspace AS Knutsrødveien 7 N-3189 Horten	Mrs Cecilie Berg Tel: (+47) 3303 2700
Norway	Fax: (+47) 3303 2800 email: <u>cecilie.berg@norspace.no</u>

Initial Qualification

Qualification Certificate No.	Validity Dates	Type Designation
313	• •	SAW filters (transversal band pass/resonator/notch/low loss impedance element)

Maintenance of Qualification

Qualification Certificate No.	Validity Dates	Comment

Applicable Documents

ESCC Generic Specification No. 3502

ESCC Detail Specification Nos. 3502/002

Norspace Process Identification Documents:

PID534_3 SAW Device Assembly with flow NORSF-A1 PID630_4 SAW Crystal Manufacturing with flow NORSF-C1

List of Qualified Components

For each design a detail specification is produced by Norspace. Where the SAW component is not proprietary to the customer the detail specification is published in ESCIES as a supporting document. Available detail specifications are found in the table below.

Component Type
SAW Filters, Hermetically Sealed, Surface Mount, Frequency Range 10 MHz - 4 GHz



Technology Flow Abstract

1. Technology Flow

The Technology Flow covers the design, fabrication, assembly, screening, in-process control and testing of the Norspace SAW filters manufactured within the NORSF-C1 and NORSF-A1 processes. The design, crystal manufacturing, assembly, screening and testing is performed in the Norspace facility at Knudsrødveien 7 in Horten, Norway.

Technology Flow	Scope
Design	Norspace specification Ko 03.00
Crystal manufacturing	Process flow NORSF-C1 on purchased SAW-grade surface polished wafers. <u>Wafer materials</u> : Quartz (SiO2), Lithium niobate (LiNbO3), Lithium tantalate (LiTaO3), Langasite (La3Ga5SiO14) <u>Wafer dimensions</u> : 3" diameter 0.5 mm thick 3" diameter 1.0 mm thick 4" diameter 1.5 mm thick
Assembly	 Process flow NORSF-A1. Crystal dimensions: from 1.7 mm x 3.1 mm up to 8 mm x 76 mm. Packages: Gold plated Fe-Ni-Co-alloy flat packs. From 4 up to 50 leads with ceramic or glass feedthroughs. External wings for screw attach on some types Package dimensions: From 8 mm x 8 mm up to 85 mm x 12 mm. Gold plated Fe-Ni-Co-alloy flat packs with Cu-W base, 4 or 6 leads and ceramic feedthroughs. Package dimensions: From 11 mm x 11 mm up to 7 mm x 21 mm. Gold plated ceramic Leadless Chip Carrier (LCC) package, 10 solder pads. Package dimension: 5 mm x 7 mm.



Technology Flow	Scope	
Screening and Test	 Incoming inspection In-process inspection 100% Wafer probe electrical test 100% Visual inspection Final production tests Customer Source Inspection Screening Burn-in and electrical measurements Test procedures External visual inspection Qualification testing Lot acceptance testing 	

(a) Basic Information

The SAW devices are passive devices and typically require external tuning. Frequency range: From 10 MHz up to 4 GHz.

Max operating temperature range: -30 / +85 C (maximum), -20 / +70 C (typical). Input power: design sensitive.

- (b) Component Types
 - Transversal band pass SAW filters with frequencies up to 4 GHz.
 - SAW Resonator filters
 - SAW Notch filters
 - Impedance element filters with low loss
- 2. Design

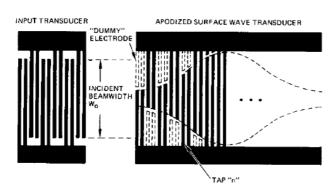
The design programs are in-house developed procedures and libraries. Each new design is custom made for the application by Norspace design engineers. The design centre is in Horten, Norway.

(a) Transversal band pass SAW filters

The transversal filters consist of one input transducer and one output transducer, see figure below. The transducers are interdigital transducers formed by a metal pattern on a piezoelectric material (wafer). The transducers can be withdrawal weighted and/or length (apodization) weighted. The detailed weighting functions are calculated in a dedicated filter synthesis software and used as input to the mask layout software. The simulation of the filter response is performed by a dedicated SAW Analysis software.

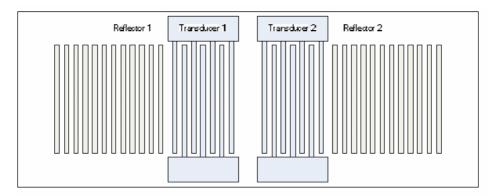


ISSUE 10



(b) Resonator filters

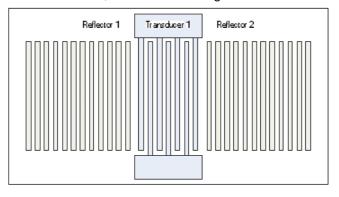
The resonator filter consists of input and output transducers as described above. These are normally unweighted. The transducers are backed by reflectors, see figure below. The reflectors are I/4 wide etched grooves or metal fingers. The same software is used for simulation of the transducers and reflectors.



(c) SAW Notch filters

The notch are based on single port resonator elements, so called impedance elements (see below).

Impedance element filters with low loss
 Impedance element filters are constructed from one port SAW resonators. The one port SAW resonators consist of one interdigital transducer backed by one reflector on each side, as shown in the figure below.



3. Fabrication

The NORSF-C1 process at Norspace comprises



- SAW crystal manufacturing on SAW grade polished single crystal wafers from quartz, LiNbO₃, LiTaO₃ and La₃Ga₅SiO₁₄ (langasite)
- Externally purchased SAW wafers
- SAW wafer thickness between 0.5 mm and 1.5 mm
- Photolithography with line widths down to 0.3 m. No upper limit.
- Metallization performed with Al or Cr/Al. Metal thickness 400 to 10 000 Å.
- The process can manufacture SAW elements of band pass, resonator or notch type with centre frequencies in the range 10 MHz to 4 GHz.

4. Assembly

Norspace assembly flow NORSF-A1 technology flow covers the following capabilities:

Package	Die Attach	Wire Bond	Lid Seal	Leads
Flatpack/LCC. Au plated. CuW base/ Fe-Ni-Co alloy or ceramic with Fe-Ni-Co alloy seal ring.			Resistance seam sealing. N2 atmosphere.	Au plated

5. Test

Measurements are performed using a Vector Network Analyzer (VNA),

All equipment in the electrical test set-up shall have the same characteristic impedance. The S-parameters are measured on the VNA and transferred to a PC for post-processing and analysis. Before testing the VNA and its test cables must be calibrated as specified in the manual for the instrument (full 2-port calibration).

Test vehicles used for qualification: SQF-3800, SLC-4320.

Test vehicles used for maintenance: SQF-3800, SLC-3900, or similar devices.

6. Radiation

- The devices are regarded as radiation insensitive within a small drift in centre frequency and phase allowed for in the design margins.
- Radiation testing has been performed successfully up to 50 MRad(Si) for quartz and 1
- MRad(Si) for LiNbO3, LiTaO3 and Langasite.

Qualified wafer materials: Quartz, LiNbO3. LiTaO3, Langasite (La $_3$ Ga $_5$ SiO1



5.4 <u>ATMEL</u>

Address	ESCC Chief Inspector
Atmel Nantes BP 70602 44306 Nantes Cedex 3 France	Mr C. Ferré Tel. +33 24 01 81 913 FAX +33 24 01 81 946

Initial Qualification

Validity Dates	Type Designation
•	Integrated Circuits, Silicon, Monolithic, CMOS, Cell-Based Array, based on Type ATC18RHA

Maintenance of Qualification

Qualification Certificate No.	Validity Dates	Comment

ESCC Generic Specification No. 9000

ESCC Detail Specification No. 9202/080

Atmel Process Identification Document PID 0030

List of Qualified Components

For each ASIC design an ASIC Sheet is produced by Atmel for use in conjunction with the ESCC Detail Specification No. 9202/080. Where the ASIC is not proprietary to the customer the ASIC sheet is published in ESCIES as a supporting document. Availability of the ASIC sheet is indicated in the table by an * in the final column.

ASIC Sheet	Component Type	ESCIES



In the case of ATC18RHA, standard components are also available. These are listed below with their full ESCC Detail Specification.

Detail Specification	Component Type	ESCIES
9512/004	Integrated Circuits, Silicon, 32-bit SPARC Processor, based on Type AT697F	*

1. Technology Domain Abstract

ATC18RHA standard cells family is designed with a 0.18µm radiation hard CMOS technology. This offering is based on 6 metal layers at 1.8V +/-0.15V for the core and 3.3V +/-0.3V for the periphery. This family features arrays with up to 6.5 Mgates and 544 pads. With its high speed performance, its low supply current and its radiation hard level, the ATC18RHA is suitable for digital applications working in radiation intensive environment.

The Technology Flow Definition domain covers the design, fabrication, assembly and testing of the ATC18RHA standard cells family.

	Scope	Site
Design Centre	Matrix Sizes: ATC18RHA95_216: 1.1 Mgates ATC18RHA95_324: 2.2 Mgates ATC18RHA95_404: 3.5 Mgates ATC18RHA95_504: 5.5 Mgates ATC18RHA95_544: 6.5 Mgates ATC18RHA95_544: 6.5 Mgates ATC18RHA95_544: 6.5 Mgates	Atmel Nantes BP 70602 44306 Nantes Cedex 3 France
Wafer Fabrication	Process Flow: AT58KRHA	LFoundry Zone Industrielle 131106 Rousset Cedex France
Assembly	Packages: - Multilayer Quad Flat Pack 100, 160, 196, 256, 352 pins - Land Grid Array 349, 472 and 625 pins - MCGA 349, 472	E2V Grenoble BP 123 38521 Saint-Egrève Cedex France
Test		
	Lot Formation Wafer Acceptance Inspection - SEM - Wafer Lot Acceptance In-process Inspection Test Testing Flow	Atmel Nantes BP 70602 44306 Nantes Cedex 3 France



Scope	Site
Sampling Plans	
Test Procedures	
- Test Vector Generation	
- Test Program Validation	
Customer Source Inspection	
Qualification Testing	
Lot Acceptance	
Support Qualification Test Plan/Report	
Technology Characterization	
Reliability Monitoring	
Incoming Inspection	Atmel Nantes
Final Test	Atmel Nantes
- Credence, Type Octet	BP 70602
Screening	44306 Nantes Cedex 3
External Visual Inspection	France

- (a) Basic Information
 - CMOS technology AT58KRHA
 - 40 to 70 kgates per mm² Up to 6.5M gates
 - Double supply operation
 - Periphery power supply 3.3V
 - Core power supply 1.8V
 - Low supply current : Operating maximum value: 85nW/gate/MHz with a duty cycle at 20%
 - I/O Interfaces:
 - Cold sparing
 - High speed LVDS (655 Mps) and LVPECL
 - PCI
 - 544 pads (+ 8 pads power only)
 - Embedded memories: Compiled and Synthesized
 - EDAC library
 - Radiation:

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- No Single Event Latch-Up below a LET Threshold of 80 MeV/mg/cm² at ambient & high temperature
- SEU hardened DFF's to 30 MeV/mg/cm2
- Tested up to 300 KRad (Si), Radiation Level is 100 KRads (Si).
- Five Matrices
 - Device Types per individual custom ASIC sheets and ESCC Detail Specification 9202/080

Matrix	Supply Voltage I/O / core	Max programmable I/O's	Case	Typical Routable gates
ATC18RHA95_216	3.3V/1.8V	216	MQFP-F256	1.1 M
ATC18RHA95_216	3.3V/1.8V	216	MQFP-F196	1.1 M
ATC18RHA95_216	3.3V/1.8V	216	MQFP-F160	1.1 M
AT697F	3.3V/1.8V		MQFP-F256	0.85 M
AT697F	3.3V/1.8V		LGA- 349	0.85 M



ATC18RHA95_324	3.3V/1.8V	324	MQFP-T352	2.2 M
ATC18RHA95_324	3.3V/1.8V	324	MQFP-F256	2.2 M
ATC18RHA95_324	3.3V/1.8V	324	MQFP-F196	2.2 M
ATC18RHA95_324	3.3V/1.8V	324	MQFP-F160	2.2 M
ATC18RHA95_324	3.3V/1.8V	324	LGA-349	2.2 M
ATC18RHA95_404	3.3V/1.8V	404	MQFP-T352	3.5 M
ATC18RHA95_404	3.3V/1.8V	404	MQFP-F256	3.5 M
ATC18RHA95_404	3.3V/1.8V	404	LGA-472	3.5 M
ATC18RHA95_404	3.3V/1.8V	404	LGA-349	3.5 M
ATC18RHA95_504	3.3V/1.8V	504	MQFP-T352	5.5 M
ATC18RHA95_504	3.3V/1.8V	504	MQFP-F256	5.5 M
ATC18RHA95_504	3.3V/1.8V	504	LGA-625	5.5 M
ATC18RHA95_504	3.3V/1.8V	504	LGA-472	5.5 M
ATC18RHA95_504	3.3V/1.8V	504	LGA-349	5.5 M
ATC18RHA95_544	3.3V/1.8V	544	LGA-625	6.5 M
ATC18RHA95_544	3.3V/1.8V	544	AIN LGA-625	6.5 M

(b) 1.3 Component Types

This table presents the available couples (matrix, package) as defined in the Detail Specification.

	ATC18RHA	AT697F	ATC18RHA	ATC18RHA	ATC18RHA	ATC18RHA
	95_216		95_324	95_404	95-504	95-544
MQFP-T352			Х	Х	Х	
MQFP-F256	Х	Х	Х	Х	Х	
MQFP-F196	Х		Х			
MQFP-160	Х		Х			
MQFP-100	Х					
LGA 625 AIN						Х
LGA 625					Х	Х
LGA 472				Х	Х	
LGA 349		Х	Х	Х	Х	
MCGA 472				Х	Х	
MCGA 349		Х	Х	Х	Х	

2. Design

The design manual and the ASIC library data books cover design at the Atmel Nantes Design Centre.

- ATC18RHA Design Manual ATD-DE-GR-R0212
- ATC18RHA Buffers library databook ATD-TS-LR-R0252
- ATC18RHA Cells library databook ATD-TS-LR-R0251
- ATC18RHA Memory cells library databook ATD-TS-LR-R0254
- ATC18RHA specific library databook ATD-TS-LR-R0253

All ASIC designs will be performed by the customer at the customer site, with Atmel supported tools (front end).

3. Fabrication

The ATC18 Radiation Tolerant process at LFoundry Rousset is a 0.18 µm CMOS, 6 metal, Ti, TiN and AlCu process.



4. Assembly Atmel Nantes assembles the ATC18RHA devices at E2V Grenoble.

This Technology Flow covers the following capabilities.

Package	Die Attach	Wire Bond	Lid Seal	Leads
MQFP	Cyanate ester (JM7000)	Ultrasonic Wedge, 32 µm	Brazed Sealed with Au/Sn	Au Plated
		AI	Alloy	
LGA	Cyanate ester	Ultrasonic	Brazed Sealed	Au Plated
	(JM7000)	Wedge, 32 µm	with Au/Sn	
		Al	Alloy	

5. Test

Atmel Nantes tests the ATC18RHA devices at Atmel Nantes.

(a) TCVs and SEC

The matrix ATC18RHA95_324: 2.2 Mgates is used for both test vehicles.

Test Vehicle V41

The V41 is a buffer test vehicle representative of the range of buffers available for performance testing in the MQFP 256 package. It contains standard IO33 buffers, specific IO33 buffers (LVDS,PCI), a PLL, a set of ring oscillators made of different library cells and a set of interconnect lines.

- Test Vehicle V40 - SEC

The V40 SEC is developed for performance and radiation testing in the MQFP 256 package.

It contains a set of memory blocks (compiled memories with and without EDACs and synthesized (on gates) memories made with standard and hardened latches), shift registers chains and a PLL.

(b) The use of Transistion Delay Fault (TDF) vectors are recommended.

6. Radiation Characteristics

The AT58KRHA family has been developed to fulfil the following characteristics in term of radiation tolerance:

- Total dose tested up to 300 krad (Si). Radiation Level is 100 KRads.
- No Single Event Latchup below a LET threshold of 80 MeV/mg/cm² at ambient & high temperature.
- Availability in the library of SEU hardened cells.



ISSUE 10

The radiation capability of the ATC18RHA family has been tested during the development phase and evaluated in total dose and for single event effects. These tests have confirmed the above characteristics. Radiation verification test is performed under customer requirement.